

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
Bhushan L. Sopori)	Group Art Unit: 1797
Application No.: 10/535,291)	Examiner: Samuel P. SIEFKE
Filed: May 16, 2005)	Confirmation No.: 5821
Attorney Docket No.: NREL 02-15)	<u>PETITION FOR EXTENSION OF TIME</u>
For: WAFER CHARACTERISTICS VIA REFLECTOMETRY)	

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In connection with the Request for Continued Examination submitted September 2, 2009, Applicants respectfully petition for an extension of time under 37 C.F.R. § 1.136(a) of two (2) months to respond to the final Office Action dated April 13, 2009, for the above-identified application.

The required fee of \$490.00 is being submitted via EFS-Web concurrently with the filing of this paper. Please credit any overpayment or debit any underpayment to Deposit Account No. 14-0460.

Respectfully submitted,

Dated: September 2, 2009

/John C. Stolpa/
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